

六方晶窒化ホウ素薄膜とその製造方法(吾郷教授_九州大学)の関連論文

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2. Y. Uchida, H. Ago et al., Controlled Growth of Large-Area Uniform Multilayer Hexagonal Boron Nitride as an Effective 2D Substrate, ACS Nano, 12, pp.6236-6244 (2018)